Physical Property Improvement of Atomic Layer Deposited Thin-film Interconnects

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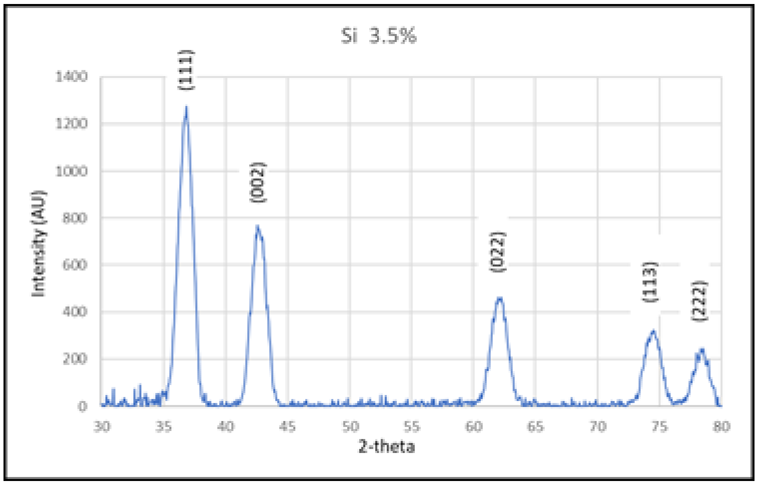

Figure 1

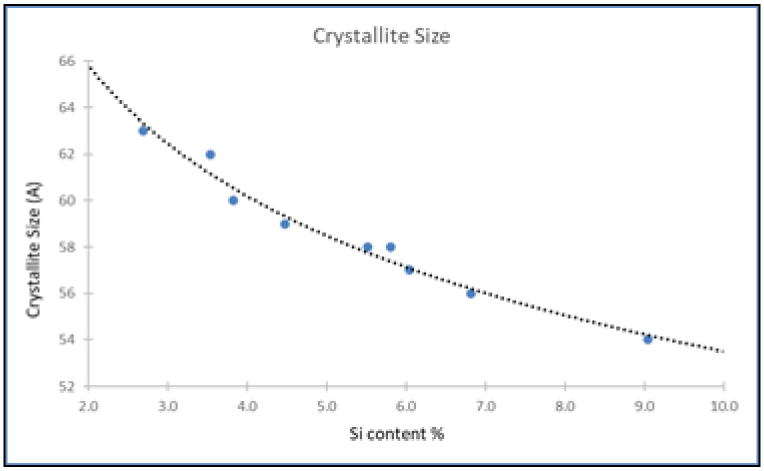

Figure 2

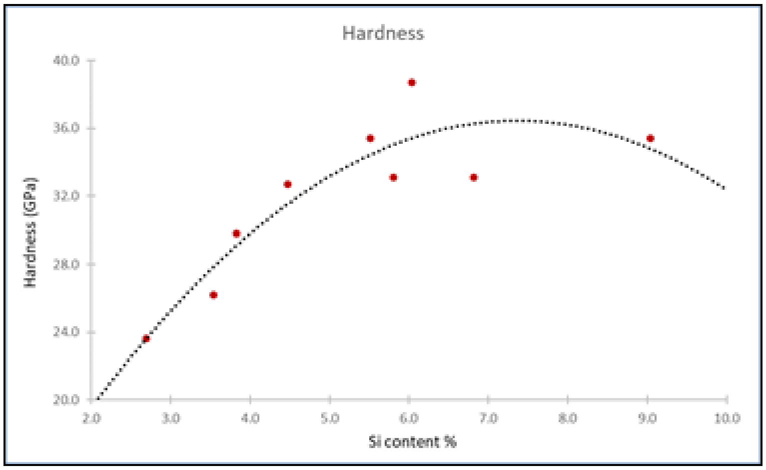

Figure 3

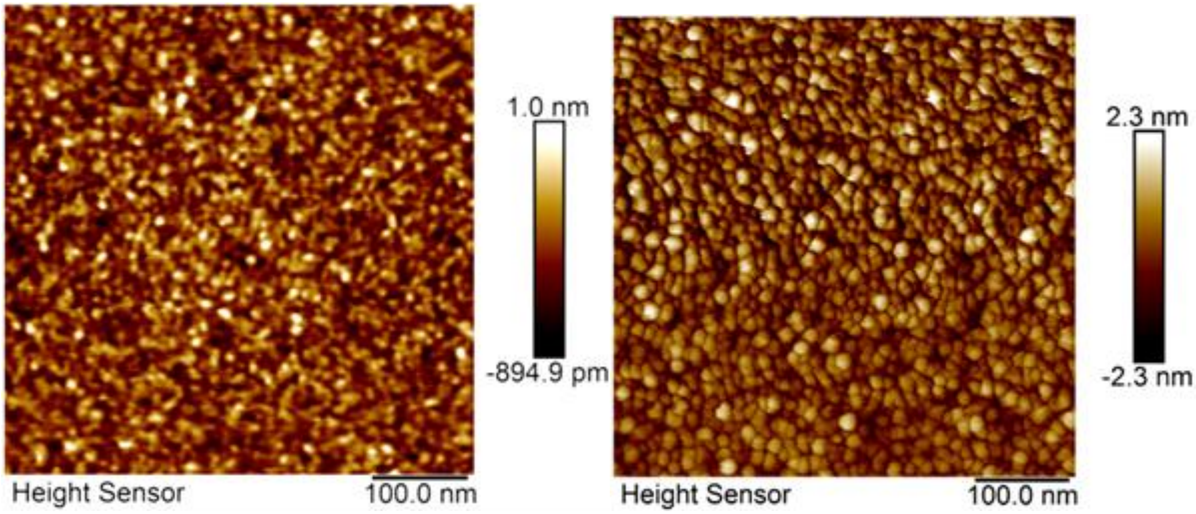

Figure 4

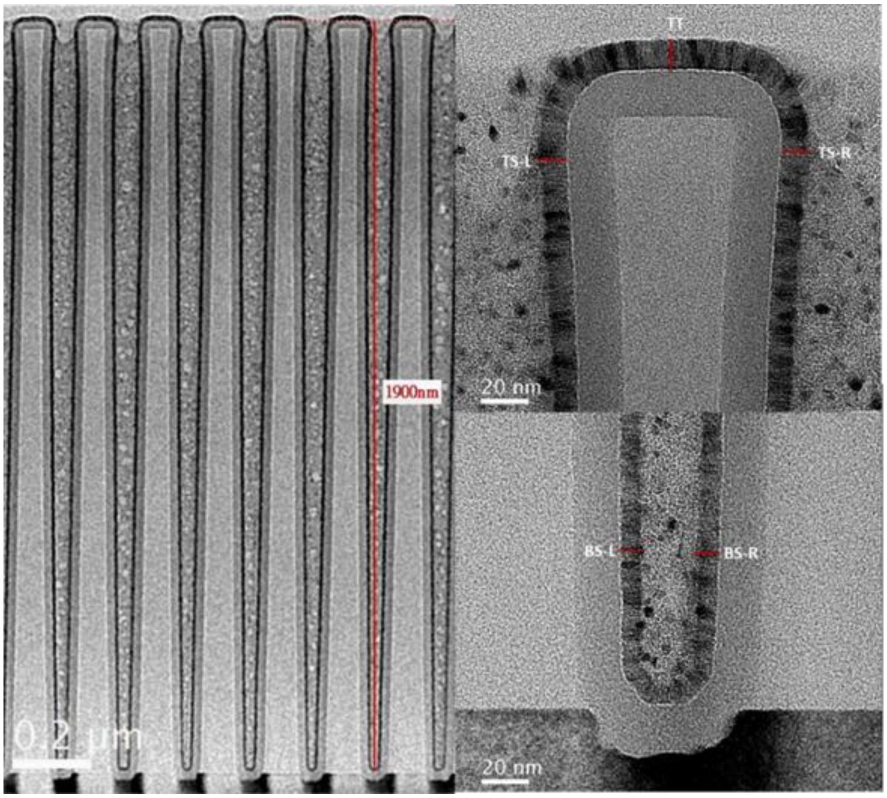

Figure 5